

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the application of

Rene George et al.

Serial No: ~~10/348,102~~ 10/803,453 <sup>PF</sup>

Filed: March 18, 2004

For: **SLOTTED ELECTROSTATIC SHIELD  
MODIFICATION FOR IMPROVED ETCH  
AND CVD PROCESS UNIFORMITY**

)  
) Examiner: Luz L. Alejandro

)  
) Art Unit: 1763

)  
) Attorney Docket: MAT-8

)  
)  
) Date: February 22, 2005  
)

**CERTIFICATE OF ELECTRONIC TRANSFER** I hereby certify that this correspondence is being electronically transmitted to the United States Patent and Trademark Office on February 22, 2005.

Signed: 

Jay R Beyer

Commissioner of Patents  
P.O. Box 1450  
Alexandria, VA 22313

**RESPONSE TO RESTRICTION REQUIREMENT WITH REQUEST FOR RECONSIDERATION**

Dear Sir:

The following remarks are intended as a full and complete response to the outstanding Office Action dated (mailed) January 24, 2005.

MAT-8

1

USSN 10/803,453

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the application of

Rene George et al.

Serial No: 10/803,453

Filed: March 18, 2004

For: **SLOTTED ELECTROSTATIC SHIELD  
MODIFICATION FOR IMPROVED ETCH  
AND CVD PROCESS UNIFORMITY**

Examiner: Luz L. Alejandro

Art Unit: 1763

Attorney Docket: MAT-8

Date: August 22, 2005

**CERTIFICATE OF ELECTRONIC TRANSFER** I hereby certify that this correspondence is being electronically transmitted to the United States Patent and Trademark Office on August 22, 2005.

Signed: 

Jay R Beyer

Commissioner of Patents  
P.O. Box 1450  
Alexandria, VA 22313

**RESPONSE TO RESTRICTION REQUIREMENT WITH REQUEST FOR RECONSIDERATION**

Dear Sir:

The following remarks are intended as a full and complete response to the outstanding Office Action dated (mailed) January 24, 2005.

MAT-8

1

USSN 10/803,453